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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/001,575	11/02/2001	Mark P. D'Evelyn	120461-1	2745
7590 02/24/2004			EXAMINER	
HANH. T. PHAM			LANGEL, WAYNE A	
GENERAL ELECTRIC COMPANY-LEGAL				
ONE PLASTICS AVENUE			ART UNIT	PAPER NUMBER
PITTSFIEND,, MA 01201			1754	

DATE MAILED: 02/24/2004

Please find below and/or attached an Office communication concerning this application or proceeding.



UNITED STATES DEPARTMENT OF COMMERCE Patent and Trademark Office Address: COMMISSIONER OF PATENTS AND TRADEMARKS Washington, D.C. 20231

APPLICATION NUMBER	FILING DATE	FIRST NAMED APPLICANT	ATTORNEY DOCKET NO.

EXAMINER PAPER NUMBER ART UNIT

DATE MAILED:

This is a communication from the examiner in charge of your application.

COMMISSIONER OF PATENTS AND TRADEMARKS	
OFFICE ACTION SUMMARY	·
Responsive to communication(s) filed on	
☐ This action is FINAL.	
☐ Since this application is in condition for allowance except for formal matters, pro accordance with the practice under <i>Ex parte Quayle</i> , 1935 D.C. 11; 453 O.G. 21	secution as to the merits is closed in
A shortened statutory period for response to this action is set to expire whichever is longer, from the mailing date of this communication. Failure to respon the application to become abandoned. (35 U.S.C. § 133). Extensions of time may \$1.136(a).	month(s), or thirty days, d within the period for response will cause pe obtained under the provisions of 37 CFR
Disposition of Claims	
Claim(s)	is/are pending in the application.
Of the above, claim(s)	is/are withdrawn from consideration.
X Claim(s)	is/are allowed.
Claim(s)	is/are rejected.
☐ Claim(s)	
☐ Claims	are subject to restriction or election requirement.
Application Papers	
See the attached Notice of Draftsperson's Patent Drawing Review, PTO-948.	
☐ The drawing(s) filed on is/are	objected to by the Examiner.
☐ The proposed drawing correction, filed on	is 🗌 approved 🗌 disapproved.
☐ The specification is objected to by the Examiner.	
☐ The oath or declaration is objected to by the Examiner.	
Priority under 35 U.S.C. § 119	
Acknowledgement is made of a claim for foreign priority under 35 U.S.C. § 119	9(a)-(d).
☐ All ☐ Some* ☐ None of the CERTIFIED copies of the priority docum	
received.	
received in Application No. (Series Code/Serial Number)	
received in this national stage application from the International Bureau (Po	CT Rule 17.2(a)).
*Certified copies not received:	
☐ Acknowledgement is made of a claim for domestic priority under 35 U.S.C. §	119(e).
Attachment(s)	
Notice of Reference Cited, PTO-892	
Information Disclosure Statement(s), PTO-1449, Paper No(s).	
☐ Interview Summary, PTO-413	
☐ Notice of Draftsperson's Patent Drawing Review, PTO-948	
Notice of Informal Patent Application, PTO-152	
CEE OFFICE ACTION ON THE FOLLOW	ING PAGES

Serial No. 10/001,575 Art Unit 1754

The following is a quotation of the appropriate paragraphs of 35 U.S.C. ' 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

The following is a quotation of 35 U.S.C. ' 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1-6 are rejected under 35 U.S.C. 102(b) as anticipated by or, in the alternative, under 35 U.S.C. 103(a) as obvious over Suscavage et al. It would be expected that the polycrystalline gallium nitride formed according to the process of Suscavage et al. would have the properties as recited in applicant's claims 1-6, since Suscavage et al. teach at column 2, lines 62-67 that the "green" compact formed according to the third processing option can be reinserted into the same processing apparatus that the original powder was synthesized to infiltrate the open pores with the same Group III metal nitride, which would produce a high density, thick target. There is no evidence on record showing that such a high density target would not have an apparent density of between about 5.5 and 6.1 g/cm³. Compared to Example 3 found on pages 6 and 7 of applicant's specification does not include the reinsertion of the "green" compact into the same processing apparatus that the original powder was synthesized to infiltrate the open pores with gallium nitride. Accordingly the comparison is not performed with the closest prior art, since the closest prior art would appear to be that embodiment in Suscavage et al. wherein the "green" compact is reinserted to infiltrate the open pores with gallium nitride.

Claims 1-6 are rejected under 35 U.S.C. '112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention. It is indefinite as to whether the "apparent density" and "Vickers hardness" recited in lines 2 and

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3, respectively, of claim 1 refers to the polycrystalline gallium nitride. It is suggested that claim 1 be rewritten as follows to avoid this rejection.

--Claim 1. Polycrystalline gallium nitride (GaN) having an apparent density of between about 5.5 and 6.1 g/cm^3 , a Vickers hardness of above about 1 GPa, and wherein the atomic fraction of gallium ranges from between about 49% to 55%.

Claims 7-27 are allowed.

The other references are made of record for disclosing various methods for producing polycrystalline gallium nitride.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Wayne A. Langel whose telephone number is (571) 272-1353. The examiner can normally be reached on Monday through Friday from 8 A.M. to 3:30 P.M.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Stanley Silverman, can be reached on (571) 272-1358. The fax phone number for this Group is (703) 872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either private PAIR or public PAIR. Status information for unpublished applications is available through private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

WAL:cdc February 18, 2004

> MAYNE A. LANGEL PRIMARY EXAMINER